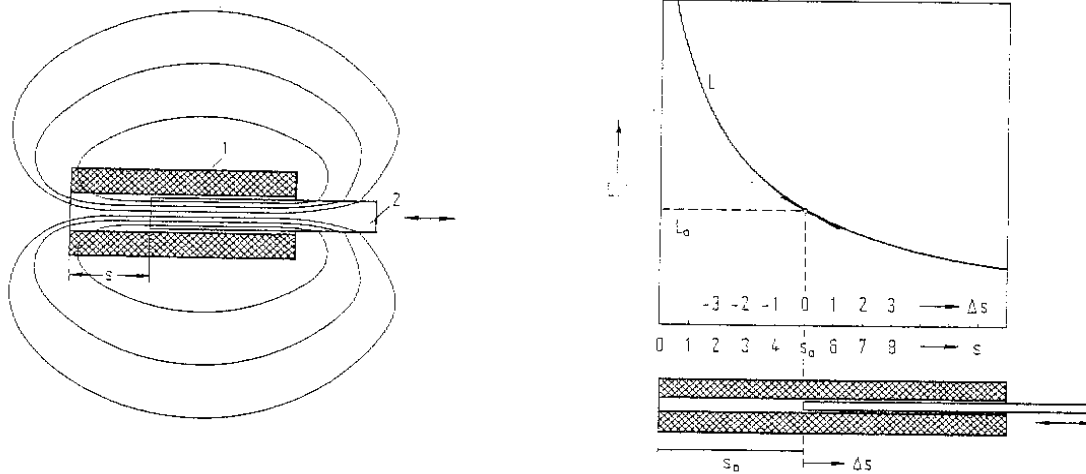


8. Messsysteme mit L- und C-Sensoren

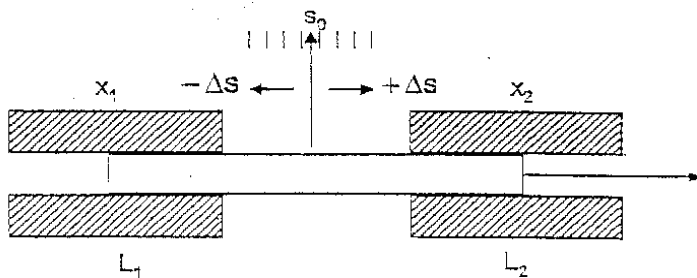
8.1 Sensoren

a) induktive Sensoren

- Tauchanker-Aufnehmer (Einzel-Sensor)



- Differential-Tauchanker-Aufnehmer (Doppel-Sensor)



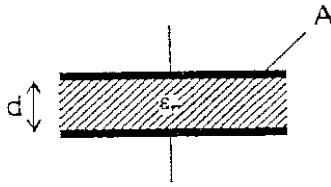
- 2 getrennte Spulen
- 1 Eisenkern

$$\left\{ \begin{aligned} L_1 &= \frac{k}{s_1} = \frac{k}{s_0 + \Delta s} \\ L_2 &= \frac{k}{s_2} = \frac{k}{s_0 - \Delta s} \end{aligned} \right.$$

Mittelstellung: s_0

b) kapazitive Sensoren

- Plattenkondensator (Einzel-Sensor)

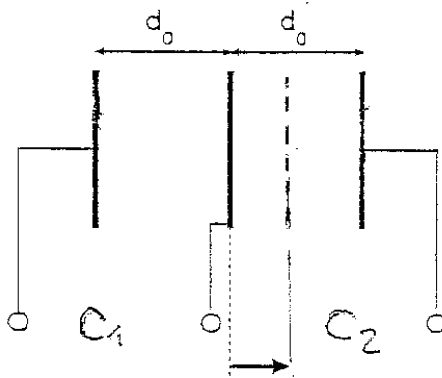


$$C = \frac{\epsilon_0 \epsilon_r A}{d}$$

Variation des Plattenabstandes:

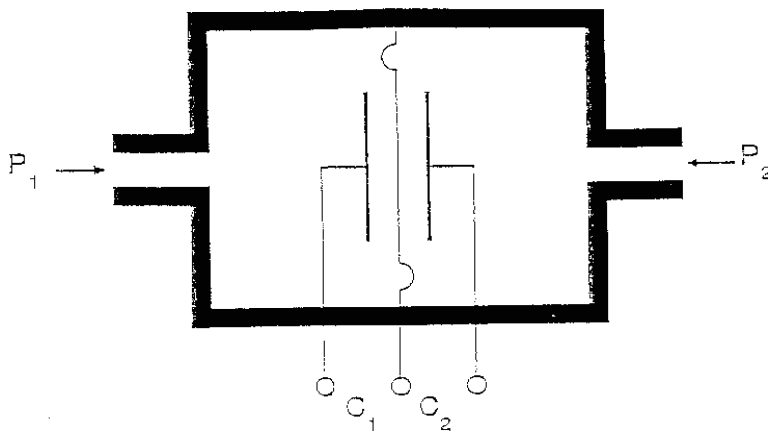
$$E = \frac{dC}{dd} = -\frac{\epsilon_0 \epsilon_r A}{d^2} = -\frac{C}{d}$$

- Differential- Plattenkondensator (Doppel-Sensor)



Anwendung:

Weg-Messung
Winkel-Messung
Kondensatormikrophon

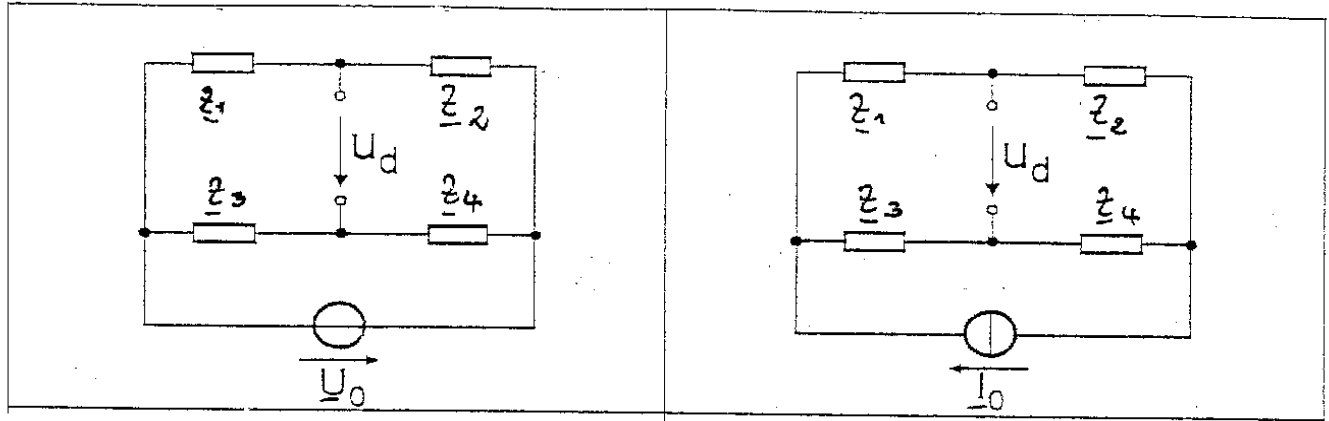


8.2 Messung komplexer Widerstände

a) digitale Messmethoden

Schwingkreis --> Frequenz-, Periodendauermessung
 RC-Messungen mit Relaxationsoszillatoren, DualSlope-Methoden
 Korrelative Messungen

b) Wechselstrom-/Wechselspannungsbrücken



unbelastet:

$$\underline{U}_d = \underline{U}_0 \cdot \frac{\underline{Z}_2 \underline{Z}_3 - \underline{Z}_1 \underline{Z}_4}{(\underline{Z}_1 + \underline{Z}_2)(\underline{Z}_3 + \underline{Z}_4)}$$

unbelastet:

$$\underline{U}_d = \underline{I}_0 \cdot \frac{\underline{Z}_2 \underline{Z}_3 - \underline{Z}_1 \underline{Z}_4}{\underline{Z}_1 + \underline{Z}_2 + \underline{Z}_3 + \underline{Z}_4}$$